GOLUBTSOV, S. A.

I. V. Trofimova, K. A. Andrianov and S. A. Golubtsov, "The Synthesis of Trichlorsilane."

Report presented at the Second All-Union Conference on the Chemistry and Fractical Application of Silicon-Organic Compounds held in Leningrad from 25-27 September 1958.

Zhurnal prikladnoy khimii, 1959, Nr 1, pp 238-240 (USSR)

ANDRIANOV, K.A.; GOLUETSOT, S.A.; TISHINA, N.N.; TROFIMOVA, I.V.

Direct synthesis of phenyltrichlorosilane in a fluidised bed.
Zhur.prikl.khim. 32 no.1:201-207 Ja '59. (HIRA 12:4)
(Silane)

## "APPROVED FOR RELEASE: 06/13/2000

CIA-RDP86-00513R000515920010-8

75687 \$0V/80-32-10-36/51

5.3600

Andrianov, K. A., Golubtsov, S. A., Trofimova, I. V.,

AUTHORS:

Lobusevich, N. P.

TITLE:

Direct Synthesis of Methylchlorosilanes in a Fluidized

Bed

PERIODICAL:

Zhurnal prikladnov khimii, 1959, Vol 32, Nr 10, pp

2332-2335 (USSR)

ABSTRACT:

The present work was done in 1954-1955. The effectiveness of the fluidized bed application was checked by

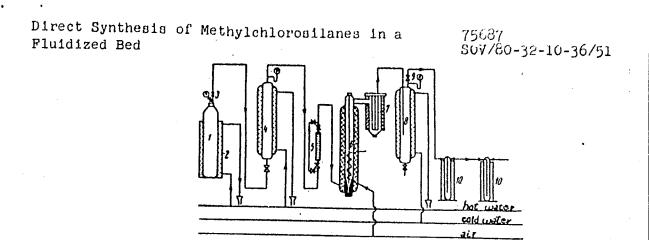
the synthesis of methylchlorosilanes. The reaction between methyl chloride and silicon was carried out in the presence of a silicon-copper alloy (20% Cu), at 4-5 atmospheres pressure. The reaction is exothermic and needs to be cooled. Special apparatus was constructed which included a cooling system. Dimethyldichlorosilane content was between 42 and 47% in the reaction mixture. A schematic diagram of the apparatus is given,

where 1 is methyl chloride cylinder; 2 is water bath;

Card 1/2

## "APPROVED FOR RELEASE: 06/13/2000

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3 is valve; 4 is evaporator, heated with hot water; 5 is rotameter, 6 is reactor, 7 is filter; 8 is water-cooled trap; 9 is valve; 10 is traps cooled with dry ice and acetone. There are 2 figures; 2 tables; and 4 Soviet references.

May 15, 1958

SUBMITTED:

5.3700(B)

Golubtsov, S. A.,

s/020/60/131/01/025/060

B011/B006

AUTHORS:

Andrianov, K. A., Corresponding Member, AS USSR,

Tishina, N. N.

TITLE:

Reaction of Joint Phenylation of Trichlorosilane and Silicon

Tetrachloride

PERIODICAL:

Doklady Akademii nauk SSSR, 1960, Vol 131, Nr 1, pp 91-93

(USSR)

ABSTRACT:

The authors intended to eliminate the side reactions which lower the yield to 40% theoretical phenyltrichlorosilene (Ref 5), and at the same time tried to phenylate the silicon tetrachloride formed in the reaction. They found that the hydrogenation of silicon tetrachloride with hydrogen proceeds satisfactorily, if the reagents are heated under the same conditions as bring about the phenylation of trichlorosilene (440-460°, 180 atm). The results obtained proved that it is fundamentally possible to phenylate SiCl<sub>4</sub>, if it is first

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hydrogenated to trichlorosilane, and only then reacted with benzene. The hitherto unused hydrogen formed as a by-product

Reaction of Joint Phenylation of Trichlorosilane and Silicon Tetrachloride

68812 \$/020/60/131/01/025/060 B011/B006

in reaction (1) was utilized for the first stage of this process. For this purpose, the authors reacted a mixture of SiCl<sub>4</sub>, C<sub>6</sub>H<sub>6</sub>, and trichlorosilane (Ref 6) under the abovementioned reaction conditions. The molar ratio of trichloresilane: SiCl, was varied between 0.25: 0.75 and 0.85: 0.15. It can be seen from figure 1 that the yield in phenyltrichleresilane (in g-nel per 100 g-mol of reacted trichlorosilane) increases with increasing content of SiCl<sub>4</sub> in the reaction mixture. This cannot be explained by the suppression of the disproportionation of trichlorosilane, occurring as a side reaction, since the yield in phenyltrichlorosilane often considerably exceeds 100 g-mol per 100 g-mol trichlorosilane. This proves that the phenylation proceeds according to the intended scheme (see scheme given), under utilization of the hydrogen formed in reaction (1). The increased hydrogen pressure facilitates the first reaction, i.e. hydrogenation. For this reason phenyltrichlorosilana, final product, was altained in much higher yield than it ish . . tainable at at-

Card 2/3

Reaction of Joint Phenylation of Trichlorosilane and Silicon Tetrachloride

S/020/60/131/01/025/060 B011/B006

mospheric pressure. The authors have thus proved that the phenylation of SiCl<sub>4</sub> with benzene gives sufficiently high

yields even without use of metalorganic compounds, if conditions are so chosen, that SiCl<sub>4</sub> is hydrogenated by hydrogen

to the intermediate trichlorosilane according to reaction (2). Trichlorosilane then reacts with benzene and forms phenyltrichlorosilane, regenerating hydrogen. There are 1 figure and 6 references, 5 of which are Soviet.

CUBMITTED:

November 5, 1959

Card 3/3

S/661/61/000/006/003/081 D205/D302

AUTHOR:

Golubtsov, S. A.

TITLE:

Direct synthesis of organic chlorosilanes

SOURCE:

Khimiya i prakticheskoye primeneniye kremneorganicheskekh soyedineniy; trudy konferentsii. no. 6, Doklady, diskussii, resheniye II Vses. konfer. po khimii i prakt. prim. kremneorg. soyed., Len., 1958. Leningrad. Izdvo

AN SSSR, 1961, 24-25

TEXT: The need for a more economical design of a process for direct synthesis of chlorosilanes is stressed. Two main problems are to be solved. One is the possibility of regulating the composition of the methyl chlorosilanes. The second is the design of new processes for various alkyl- and aryl chlorosilanes (including products having a functional group in the radical) based on by-products of the direct synthesis or some other readily available raw materials. There is much room for the USSR scientist in the fields of mechanisms and kinetics of the processes and also in the field of preparing new catalysts. Card 1/1

5.3700 11.1250 S/661/61/000/006/004/081 D205/D302

AUTHORS:

Trofimova, I. V., Andrianov, K. A., Golubtsov, S. A., Turetskaya, R. A., Belyakova, Z. V., Yakusheva, T. M., Lobusevich, N. P. and Luzganova, M. A.

TITLE:

On the regulation of the composition of products in the direct synthesis of methyl- and ethyl chlorosilanes in a fluidized bed

SOURCE:

Khimiya i prakticheskoye primeneniye kremneorganicheskikh soyedineniy; trudy konferentsii. no. 6, Doklady, diskussii, resheniye. II Vses. konfer. po khimii i prakt. prim. kremneorg. soyed., Len., 1958. Leningrad, Izd-vo AN SSSR, 1961, 25-27

TEXT: Regulation of the process is one of the main problems in preparing monomeric organosilicon compounds. The most intersting results were obtained during the attempt to regulate the product composition by varying the preparation procedure of the catalyst.

Card 1/3

X

On the regulation ...

S/661/61/000/006/004/081 D205/D302

This method opens wide possibilities as can be judged from the obtained data. Thus a synthesis carried out on a Si-Cu melt containing 15 - 20% Cu gave 6% CH3HSiCl2, 30 - 40% (CH3)2 SiCl2 and 40% CH3SiCl3, while the synthesis on a Si-Cu melt activated by cuprous chloride gave 6% CH3HSiCl2, 55% (CH3)2SiCl2 and 25% CH3SiCl3. Further modifications of the catalyst bring about further changes in the composition. Preliminary experiments on the production of methyl chlorosilanes from methane, were performed. Methyl dichlorosilane can be prepared in this way, with trichlorosilane and silicon by-products which can be utilized. For synthesis of ethyl chlorosilanes other methods of regulating the product composition were employed: Preliminary treatment of the Si-Cu catalyst by various gases at elevated temperatures, dilution of ethyl chloride by gases and activation of the ethyl chloride by minor additions. The most interesting results were obtained with preliminary treatment by air at 370°C. About 45% of diethyl chlorosilane was present in the product using a catalyst treated in this way. Dilution

Card 2/3

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On the regulation ...

S/661/61/000/006/004/081 D205/D302

of EtCl with HCl and the introduction of 0.5 - 0.7% moisture increases the ethyl dichlorosilane content of diethyl dichlorosilane. There are 1 figure and 3 tables.

Card 3/3

37754

\$/661/61/000/006/005/081 D205/D302

5:3700 11.1250

AUTHORS:

Lobusevich, N. P., Trofimova, I. V., Andrianov, K. A.,

Golubtsov, S. A. and Belyy, A. P.

Influence of some metal additives on the activity of TITLE:

silicon-copper alloys in the synthesis of methyl chloro-

silanes

Khimiya i prakticheskoye primeneniye kremneorganiches-SOURCE: .

kikh soyedineniy; trudy konferentsii. no. 6, Doklady, diskussii, resheniye. II Vses. konfer. po khimii i prakt. prim. kremneorg. soyed., Len., 1958. Leningrad. Izd-vo AN SSSR. 1961, 28-31

TEXT: The influence of impurities commonly encountered in silicon (Al, Fe, Ca) and copper (Bi, Sn, Pb) on the activity of siliconcopper alloys used in methyl chlorosilane synthesis was investigated. Two series of alloys were prepared: 1) From purified Si with less than 0.2% of impurities; 2) from Kp-/ (Kr-1) silicon with 2% impurities. These alloys, notwithstanding the identical procedure

Card 1/2

S/661/61/000/006/005/081 D205/D302

Influence of some ...

of preparation, were entirely different in their activity. Thus, the alloys prepared from the purified Si gave a much lower dimethyl dichlorosilane yield than those made of the non-purified Si. The average figures were 34.0% and 41.0% respectively. The introduction of Al (up to 1.5%), Fe (up to 3%), Ca (up to 0.6%), each taken separately, had very little influence on the activity of the alloys prepared from purified and non-purified Si. The use of Kr-2 silicon gives worse results. Pb and Bi have a strong detrimental influence on the activity of the alloys even at a concentration of 0.01% only, while the results obtained on the introduction of Sn were irreproducible. There are 9 tables.

1

Card 2/2

S/661/61/000/006/014/081 D205/D302

AUTHOR: Golubtsov, S. A.

TITLE: Continuous synthesis of phenyl trichlorosilane

SOURCE: Khimiya i prakticheskoye primeneniye kreneorganicheskikh soyedineniy; trudy konferentsii, no. 6, Doklady, diskussii resheniye. II Vses. Konfer. po khimii i prakt. prim. kremneorg. soyed., Len. 1958. Leningrad. Izd-vo AN SSSR,

1961, 85-86

Card 1/2

TEXT: In 1958, an apparatus for the continuous synthesis of phenyl trichlorosilane was put into production. Benzene and trichlorosilane are fed through a filter into a mixer which is connected via a cooler and surge capacitor with a column for the absorption of outlet gases. The mixture goes through filters and a high-pressure pump into a 40 liter reaction column working under high pressure and electrically heated. The products are discharged through a series of valves and a cooler into a receiver. The gases are led into the absorber and the products are collected in a capacity tank and from

Continuous synthesis of ...

S/661/61/000/006/014/081 D205/D302

there fed to rectification. Data of 4 runs ranging in duration from 45 to 98 hours are tabulated showing that the laboratory yields are fully reproduced in continuous operation. Indications are that by appropriate changes in the synthesis conditions a quantitative yield of phenyl trichlorosilane can be achieved. There are 1 figure

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S/661/61/000/006/016/081 D205/D302

5.3700

AUTHORS: Popeleva, G. S., Trofimova, I. V., Andrianov, K. A.

and Golubtsov, S. A.

TITLE:

Study of vinyl chlorosilane synthesis

SOURCE:

Khimiya i prakticheskoye primeneniye kremneorganicheskikh soyedineniy; trudy konferentsii, no. 6, Doklady, diskussii resheniye. II Vses. Konfer. po khimii i prakt. prim. kremneorg. soyed., Len. 1958. Leningrad. Izd-vo

AN SSSR. 1961, 90-94

TEXT: During the investigation of the reaction 3CH<sub>2</sub> = CHCl + Si CH<sub>2</sub> = CHSiCl<sub>3</sub> it was found that the catalyst prepared from precipitated CuO, Si powder and a liquid glass binder was the most active. 3 methods of contacting were tried: (1) Stationary bed of pelletized catalyst (2 - 3 mm pellets); (2) an agitated powder bed; (3) a fluidized bed. The first method gave good results when using anhydrous FeCl<sub>3</sub> as an activator. The second method allowed the low-Card 1/3

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Study of vinyl ...

S/661/61/000/006/016/031 D205/D302

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ering of the temperature from 460 to 420°C. The vinyl trichlorosilane yield was 33% and the output 10 - 15 g/hour/kg of catalyst. The third method resulted in a reduction of the contact time by a factor of 12 and a corresponding considerable increase in temperature. The yield of vinyl trichlorosilane was reduced, as the side methyl, ethyl and phenyl chlorosilanes where the best results are obtained in the fluidized bed, this method does not provide the contact times necessary for synthesis of vinyl chlorosilanes. As an alternative to the above reaction, the reaction HSiCl<sub>3</sub> + CH<sub>2</sub> = CHSiCl<sub>3</sub> + HCl is proposed. This reaction was investigated, yields of 65% being obtained at 500°C with a contact time of 35 seconds. Of 65% being obtained at 500°C with a contact time of 35 seconds. CH<sub>3</sub>SiHCl<sub>2</sub> + CH<sub>2</sub> = CHCl - CH<sub>3</sub>(CH<sub>2</sub>=CH)SiCl<sub>2</sub> + HCl, the optimum conditions ensuring a 55% yield were 540°C and a contact time of 30 seconds. Thus the condensation of hydrochlorosilanes with vinyl

Card 2/3

Study of vinyl ...

S/661/61/000/006/016/081 D205/D302

chloride gives a simple continuous method for preparing vinyl trichlorosilane and methyl vinyl dichlorosilane. There are 3 figures and 2 tables.

Card 3/3

S/661/61/000/006/019/081 D205/D302

Tarasova, A. S., Petrov, A. D., Andrianov, K. A., Go-lubtsov. S. A., Ponomarenko, V. A., Cherkayev, V. G., Zadorozhnyy, N. A. and Vavilov, V. V. AUTHORS:

Continuous addition of hydrochlorosilanes to unsatura-TITLE:

ted compounds

SOURCE: Khimiya i prakticheskoye primeneniye kremneorganicheskikh soyedineniye; trudy konferentsii, no. 6, Doklady,

diskussii resheniye. II Vses. Konfer. po khimii i prakt. prim. kremneorg. Soyed., Len. 1958. Leningrad, Izd-vo

AN SSSR. 1961, 99-100

TEXT: For practical application of the addition reactions of methyl dichlorosilane, ethyl dichlorosilane and trichlorosilane to liquid and gaseous unsaturated compounds an apparatus was designed and optimum conditions of synthesis were established. The chlorosilane and the gas are fed into a reactor. The products are discharged via a cooler into a receiver equipped with a reflux. Dur-

Card 1/2

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Continuous addition of ...

ing the reaction the reactor and cooler are cooled by water, the receiver and the reflux by brine. The arrangement was tested on the reaction of ethylene with methyl dichlorosilane and ethyl dichlorosilane. The experiments have shown that in the 35 - 200°C temperature range the reaction is unchanged giving a 65 - 75% yield. No by-products are formed and the output is high (> 6 kg of methyl ethyl dichlorosilane/hr/l of reactor volume). The process is amenable to automation owing to its insensitivity to temperature changes. There are 1 figure and 1 table.

Card 2/2

5.3700

AUTHORS: Golubtsov, S. A., Belyakova, Z. V., Yakusheva, T. M.

TITLE:

Synthesis of \( \beta \)-ethyl cyanide trichlorosilane

PERIODICAL: Plasticheskiye massy, no. 12, 1961, 20 - 21

Card 1/2\_

21421 \$/191/61/000/012/005/007 B110/B147

Synthesis of  $\beta$ -ethyl cyanide....

dosing vessel 1 was filled through opening 4. The reaction mixture is pressed into the reaction vessel 2 (a spiral pipe immersed into water) by N<sub>2</sub> supplied through 5. Dosing valve 7 and connector 8 are placed between 1 and 2. The mixture passes from 2 into condenser 3. The condensate reaches the receiving vessel 12. The noncondensed gases are carried off through the throttle valve 9. By means of the continuous apparatus which can easily be automatized, working is possible for a longer period under steady conditions. Productivity of the reaction vessel per unit volume increases by the twofold as compared to cyclic operation under pressure, and by the 140-fold as compared to operation under atmospheric pressure. There are 1 figure and 5 non-Soviet references. The three most recent references to English-language publications read as follows: G. D. Cooper, M. Prober, J. Org. Chem., 25, 240 (1960); J. C. Saam, J. L. Speier, J. Org. Chem., 24, 427 (1959); S. Nozakura, S. Konotsune, Bull. Chem. Soc. Japan, 29, 322 (1956).

admixtures, and 5.1% of CH3Cl. For the continuous synthesis of I (Fig.),

Card 2/3

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S/079/61/031/010/002/010

D227/D302

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AUTHORS:

Belyakova, Z.V., and Golubtsov, S.A.

TITLE:

Synthesis of some (chloro-organo) silanes

PERIODICAL:

Zhurnal obshchey khimii, v. 31, no. 10, 1961,

3178-3181

to But the surfect of the surfect of

Tri- substituted silanes in which a silicon atom is linked TEXT: to both hydrogen and a chlorinated organic radical Cl-R-Si(R') (R'')H are practically unknown in the literature. Such compounds are of interest producing polymers having chains with alternating silicon atoms and hydrocarbons. In the present work the authors prepared chloromethyl-methylphenyl silane, chloromethyldiphenylsilane and chlorophenylmethylsilane by reducing the corresponding chlorosilanes with lithium aluminum hydride. In the case of chlorophenylmethylphenylchlorosilane the reduction proceeded smoothly and the yield of chlorophenylmethylphenylsilane was 69.5 - 72% irrespective of the order of addition of the reagents. The reduction of chloromethylmethylphenylchlorosilane proved more complex;

Card 1/3

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Synthesis of some ...

when  $\text{LiAlH}_{A}$  was added to chlcrosilane the yield of product was 83% and reduction of chlorine in the chloromethyl group was practically non-existent. When the order of addition was changed the yield of chloromethylmethylphenylsilane was only 56%. The most difficult reaction occurred in the case of chloromethyldiphenylsilane; under optimum conditions, the yield of chloromethyldi-phenylsilane was only 67% and that of methyl-diphenylsilane 7%. Experimental procedure: The starting materials were prepared by reacting the corresponding dichlorosilane (chloromethylmethyldichlorosilane or chlorophenylmethyldichlorosilane) with phenylmagnesium bromide under the usual Grignard reaction conditions. The products of distillation were used in the reduction which was carried out in ether, adding the reducing agent to the chlorosilane. After completing the addition the mixture was refluxed for 6 hours, cooled and decomposed with 5% HCl. The ethereal solution was washed and distilled. Redistillation of the residue in the case of chloromethylmethylphenylchlorosilane reduction yielded chloromethylmethylphenylsilane b.pt.99-100°C/14 mm n<sub>D</sub>20 1.5326,

Card 2/3

Synthesis of some ...

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d<sub>4</sub> 1.0485 MR<sub>D</sub> 50.49; MR<sub>calc</sub> 50.69. Chloromethyldiphenylsilane and chlorophenylmethylphenylsilane were also prepared; their properties are: b.pt. 175-180°C/<sub>15 mm</sub> n<sub>D</sub> 1.5842, d<sub>4</sub> 20 1.1089, MR<sub>D</sub> 70.25, MR<sub>calc</sub> 70.46; and b.pt. 172-180°C/<sub>25 mm</sub> n<sub>D</sub> 1.5795, d<sub>4</sub> 1.0982, MR<sub>D</sub> 70.50; MR<sub>calc</sub> 70.46, respectively. There are 7 references: 3 Soviet-bloc and 4 non-Soviet-bloc. The references to the English-language publications read as follows: H. Gilman, G. E. Dunn, J. Am. Chem. Soc. 73, 3404 (1951); U.S. Patent 2,527591 (1950): G. Russell, J. Org. Chem. 21,1190 (1950); R. A. Benkeser, D. Foster, J. Am. Chem. Soc. 74, 5314 (1952).

SUBMITTED: November 14, 1960

APPROVED FOR RELEASE: 06/13/2000

Card 3/3

CIA-RDP86-00513R000515920010-8"

15.8170

**2548**0 \$/020/61/139/001/012/018 B103/B226

AUTHORS:

Andrianov, K. A., Corresponding Member AS USSR, Savushkina, V. I., Golubtsov, S. A., and Charskaya, B. A.

TITLE:

Thermal condensation of dichlero silans with chlorobenzene

PERIODICAL:

Akademiya nauk SSSR. Deklady, v. 139. no. 1, 1961, 95 - 98

TEXT: The authors studied the thermal condensation of dichloro silane with chlorobenzene  $H_2SiCl_2 + C_6H_5Cl \rightarrow C_6H_5SiHCl_2 + HCl_{1}, 30\%$  phenyl dichlorosilane resulting in the process. In addition to reaction (1), they determined the substitution of the second hydrogen atom at silicon by the phenyl group. In the presence of the high temperatures used here. (640 = 700°C), substitution of the hydrogen atom at allicon by a chlorine atom was furthermore to be expected. As a result of this complicated process, the following compounds are present among the reaction products: Diphenyl dichlorosilane and phenyl-trichlorosilane (optimum total yield together with phenyl dichlorosilane: 14.6%); furthermore, benrene (3), (4), and trichlorosilane (3). The present study proves that the yield of individual Card 1/3

25480 \$/020/61/139/001/012/018 B103/B226

Thermal condensation of dichloro...

reaction products is, above all. dependent upon temperature. Up to about  $640-660^{\circ}\mathrm{C}$  (optimum temperature of reaction (!)) the yield of phenyl dichloro silane increases up to 41.7%, and, with a further temperature rise up to  $700^{\circ}\mathrm{C}$ , it decreases to 12%. The yield of phenyl trichloro silane increases at  $640-660^{\circ}\mathrm{C}$  to 18.3%, and up to  $700^{\circ}\mathrm{C}$  continues increasing up to 26%. The yield of diphenyl dichloro silane first increases (up to 12.4% at  $660^{\circ}\mathrm{C}$ ), at  $700^{\circ}\mathrm{C}$ , however, decreases to 2.5%. These facts speak in favor of a continuously increasing rate of the reaction mentioned at the beginning. For these reasons, silane and chlorosilane are practically entirely absent in the reaction products, and in the decomposition of dichloro silane neither hydrogen (2) nor side reactions of the chlorination of chlorosilane hydrides (3), (4) have been proved to develop. The authors consider it quite probable that part of phenyl trichloro silane forms according to the scheme HSiCl<sub>3</sub> +  $C_6H_5\mathrm{Cl} \longrightarrow C_6H_5\mathrm{SiCl}_3$  + HCl (5). The rate of reactions (3), (4), and (5):  $C_6H_5\mathrm{SiHCl}_2$  +  $C_6H_5\mathrm{Cl} \longrightarrow (C_6H_5)_2\mathrm{SiCl}_2$  + HCl (2);

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Card 2/3

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Thermal condensation of dichloro...

 $H_2$ SiCl<sub>2</sub> +  $C_6H_5$ Cl  $\longrightarrow$  HSiCl<sub>3</sub> +  $C_6H_6$  (3);  $C_6H_5$ SiHCl<sub>2</sub> +  $C_6H_5$ Cl  $\longrightarrow$   $C_6H_5$ SiCl<sub>3</sub> + C6H6 (4) increases more considerably than that of (2). At 680°C the formation rates of phenyl trichloro silane tend toward similar values. Formation of trichloro silane and phenyl trichloro silane can hardly be explained other than by (3) and (4); i.e., neither by disproportionation: 2H<sub>2</sub>SiCl<sub>2</sub> → HSiCl<sub>3</sub> + H<sub>3</sub>SiCl (6) nor by decomposition of dichlero silanes  $3H_2SiCl_2 \rightarrow Si + 2HSiCl_3 + 2H_2$  (7). Also, the formation of benzene can be explained only by reactions (3) and (4), and not by pyrolysis of chlorobenzene in a reducing medium. In special experiments conducted on this pyrolysis, the authors found that the benzene yield did not exceed 9% (in hydrogen medium) and 2.2 % (in silane medium). On the other hand, in the production of phenyl dichloro silane 55 - 60 % benzene formed. Also the small yield of highly boiling products in the production of phenyl dichloro silane points to the unimportant part played by pyrolysis. S. A. Platonova and T. A. Klochkova participated in the experimental part of the study. There are 3 figures, 3 tables, and 2 Soviet-bloc references.

SUBMITTED:

March 22, 1961

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Card 3/3

5/062/62/000/006/004/008 B117/B101

AUTHORS:

Morozova, L. P., Golubtsov, S. A., Andrianov, K. A., Trofimova, I. V., and Morozov, N. G.

TITLE:

Formation of alkyl (aryl) chlorosilanes in direct reaction of alkyl (aryl) chlorides with silicon. Communication 1. Selectivity of silicon and copper catalysts, and formation

of methyl dichlorosilane

PERIODICAL:

Akademiya nauk SSSR. Izvestiya. Otdeleniye khimicheskikh nauk, no. 6, 1962, 1005 - 1011

TEXT: Production conditions, precipitating agents, and promoters affecting the selective activity of silicon and copper hydroxide catalysts in the formation of methyl dichlorosilane and dimethyl dichlorosilane were studied. Sufficiently active catalysts can be obtained by using copper chloride and copper nitrate, but copper sulfate gives completely passive catalysts. Simultaneous precipitation of copper hydroxide and zinc hydroxide (  $\sim$  2% by weight) increases the selectivity of the catalyst. Sodium hydroxide (in the formation of methyl dichlorosilane) and NHAOH or Na CO3 (in the forma-Card 1/3

S/062/62/000/006/004/008 B117/B101

Formation of alkyl ...

tion of dimethyl dichlorosilane) were found to be precipitating agents favoring the selectivity. The greatest effect on the selectivity of the catalyst is that exercised by promoters after the precipitation of hydroxicatalyst is that exercised by promoters after the precipitation of hydroxicatalyst is that exercised by promoters after the precipitation of hydroxicatalyst is that exercised by promoters after the precipitation of hydroxicatalyst is that exercised by promoters after the precipitating agents that exercised by promoters after the precipitating agents the favoring agents.

reaches 45%. Thermal decomposition of methyl chloride on copper catalysts at 360-380°C (contact time 6-10 sec) was also studied. The hydrogen chloride separated in this reaction considerably affected the formation of methyl dichlorosilane. The following reaction course was suggested for the formation of methyl dichlorosilane:

CH<sub>3</sub>Cl  $\xrightarrow{\text{catalyst}}$  HCl + carbon + hydrocarbons Si + HCl  $\longrightarrow$  [HSiCl]  $\xrightarrow{\text{CH}_3\text{Cl}}$  CH<sub>3</sub>SiHCl<sub>2</sub>

The optimum temperature for synthesizing methyl dichlorosilane was found to be 350-380°C. At higher and lower temperatures, silicon tetrachloride,

Card 2/3

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B117/B101

trichlorosilane, and methyl trichlorosilane were mainly formed. There are 4 tables.

SUBMITTED: December 9, 1961

APPROVED FOR RELEASE: 06/13/2000 CIA-RDP86-00513R000515920010-8"

1,0912 S/191/62/000/010/005/010 B101/B186

5.3833

AUTHORS:

Golubtsov, S. A., Popeleva, G. S., Andrianev, K. A., Zaslavs-kaya, N. I.

TITLE:

Thermal condensation of trichloro silane and methyl dichloro silane with vinyl chloride

PERIODICAL: Plasticheskiye massy, no. 10, 1962, 21 - 27

TEXT: Thermal condensation of vinyl chloride with methyl dichloro silane into methyl vinyl dichloro silane (I), and vinyl chloride with trichloro silane into vinyl trichloro silane (II) was conducted in a reaction tube of stainless steel under atmospheric pressure and at 30 sec contact time. Optimum reaction conditions were determined, and the condensation mechanism and thermal decomposition were studied. Results: The optimum temperature for synthesizing (I) is 530 - 540°C, the yield is 75 - 80% as referred to the reacting methyl dichloro silane. The side products are methyl trichloro silane, butadiene, high-boiling products, and gases containing 2% H<sub>2</sub>, 5% card 1/3

'S/191/62/000/010/005/010 В101/В1**8**6

Thermal condensation ...

methyl dichloro silane start in at 400°C and reaches 20% at 570°C. The gaseous decomposition products contain 75% H<sub>2</sub> and 25% CH<sub>4</sub>. The solid residue contains 65% Si but no free carbon. A radical mechanism is assumed, as the solid decomposition products catalyze the decomposition of methyl dichloro silane. The optimum conditions for the synthesis of II are: a molar ratio HSiCl<sub>3</sub>: C<sub>2</sub>H<sub>3</sub>Cl = 1:1.5 and 500 - 520°C. The yield is 70 - 75% as referred to the reacting HSiCl<sub>3</sub>, and 60% referred to the reacting vinyl chloride. If the ratio is reduced to 1:0.6, the temperature has to be raised to 560 - 580°C. A ratio of 1:1 yielded 80% II with respect to HSiCl<sub>3</sub>. The side products are equal amounts of SiCl<sub>4</sub> (15 g-moles per 100 g-moles HSiCl<sub>3</sub>) and high-boiling polymers. The gas contains 5% H<sub>2</sub>. 12% C<sub>2</sub>H<sub>4</sub>, 3% C<sub>2</sub>H<sub>6</sub>, the solid residue contains 10 - 50% Si and 30 - 75% elementary carbon. The thermal decomposition of HSiCl<sub>3</sub> in H<sub>2</sub>, SiCl<sub>4</sub>, and Si sets in at 560 - 570°C. The effect of the reaction vessel wall on the composition of the reaction products confirms the radical mechanism of the reaction. A surface increase of the reaction vessel by Raschig rings, Card 2/3

S/191/62/000/010/005/010 B101/B186

Thermal condensation ...

increases the yield of SiCl and decreases the yield of II. Purification of the reaction vessel with alkali also reduces the yield of II. A nitropen exide addition of 2% reduces the yield of II to 43% and increases that of SiCl to 13%. In the reaction of II with HCl at 560 - 570°C, the gas consists of 93% H<sub>2</sub> with 7% C<sub>2</sub>H<sub>4</sub>. There are 8 figures and 3 tables. The most important English-language references are: English Patent 752700 (1956), C. A., 51, 7402 (1957); US Patent 2770634 (1956), C. A., 51 10560 (1957), Japan Patent no. 16 (1951), C. A., 52, 3673 (1958).

Card 3/3

ANDRIANOV, K.A.; TURETSKAYA, R.A.; GOLUBTSOV, S.A.; TROFIMOVA, I.V.

Formation reactions of alkul(aryl)chlorosilanes in the direct interaction of alkyl(aryl) chlorides with silicon. Report No. 12:

Effect of hydrogen chloride on the formation of ethylchlorosilanes.

Izv. AN SSSR.Otd.khim.nauk no.10:1788-1794.0 '62. (MIRA 15:10)

(Silane) (Hydrochloric acid)

S/079/62/032/002/006/011 D204/D303

5.3700

Popeleva, G.S., Savushkina, V.I., Andrianev, K.A. and

Golubtsov, S.A.

TITLE:

AUTHORS:

Interaction of the halogen derivatives of aryl chlorosilanes

with hydrogen chlorosilanes

PERIODICAL:

Zhurnal obshchey khimii, v.32, no. 2, 1962, 557-562

TEXT: High temperature condensations of methyl dichlorosilane (I) with methyl chlorophenyl dichlorosilane (II) (reaction 1), methyl phenyl chlorosilane (III) with p-dichlorobenzene (reaction 2) and of III with methyl chlorophenyl phenyl chlorosilane (IV) (reaction 3) were investigated. Reaction 1 was carried out with 1:11 molar ratios of the reagents at 570, 600, 620, 640 and 670°C, with contact times of 40, 50, 60 and 80 sec., in stainless steel tubes and yielded a mixture of the orthor, metar and paraisomers of bis (methyl dichlorosilyl) benzene (A). It was found that the yield of A, under optimum conditions (640°C, 60 sec.), was 27%, calculated with respect to I. The product then consisted of 60% of the liquid metarisomer and 40% of the crystalline orthor and paraisomers. Reaction 2 at Card 1/2

3392<u>1</u> S/079/62/032/002/006/011 D204/D303

Interaction of the halogen ...

550°C, with a contact time of 40 sec., in silica tubes, gave IV in 34.6% yield, (calculated with respect to III), when the molar ratio of III to the p-dichlorobenzene was 2:1. Reaction 3 was carried out in silica tubes, at 650°C and with 40 sec. contact time, with reagents in 1:1 molar ratio, and gave para-bis (methyl phenyl chlorosilyl) benzene (B), in ~ 30% yield (calculated with respect to III). The structure of B was confirmed by a Grignard synthesis. Physical constants of the products and full experimental details are given. There are 2 figures, 4 tables and 15 references: 9 Soviet-bloc and 6 non-Soviet-bloc. The 4 most recent references to the English-language references read as follows: British Pat. 752,700 (1956); Ch.A., 51, 7402, (1957); Ch.A. 47, 3875, (1953); Ch.A. 47, 3334, (1953).

SUBMITTED: January 30, 1961

Card 2/2

5/079/62/032/003/004/007 D204/D302

AUTHORS:

Trofimova, I.V., Lobusevich, N.P., Golubtsov, S.A. and

Andrianov, K.A.

TITLE:

The effect of certain metallic additions to Si-Cu alloys on their activity in the reaction with methyl chloride

Zhurnal obshchey khimii, v. 32, no. 3, 1962, 841-846

PERIODICAL:

TEXT: The optimum amount of Cu and the effect of adding metals usually present in Cu and Si on the synthesis of methyl chlorosilanes were investigated, at 350-370°C, under 4 atm, by a method described earlier. Purified Si (total Al+Ca+Fe+Ti <0.2%) and Kp-1(Kr-1)Si were used, with M-1 and M-O copper. Assessment of the additions of Al, Ca, Fe, Ti, Pb, Sb and Bi was made on the basis of the yield of methyl chlorosilanes (g/kg alloy/hr) and by the selective formation of Me2SiCl2. The optimum Cu content proved to be 7-10%. Using pure silicon, Al and Ti lowered the alloy activity when present to the extent of 0.2-0.3%, whilst Fe and Ca

Card 1/2

C

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5,2700

S/079/62/032/006/006/006 D202/D304

AUTHORS:

Belyakova, Z. V., Golubtsov, S. A. and Yakusheva, T.M.

TITLE:

Synthesis of organosilicon monomers containing the

PERIODICAL: Zhurnal obshchey khimii, v.32,no.6, 1962, 1997-2003

TEXT: The authors studied the cyanoethylation of methyldichlorosilane, but with no success. Syntheses were carried out of methyl, ethyl and phenyl derivatives of B-cyanoethyldichlorosilane from the trichlorocompound. Methyl-B-cyanoethyldichlorosilane was obtained from dimethylcadmium by the method of Cooper and Prober. The pure methyl compound was isolated from the reaction products by esterification with iso-butyl alcohol. Using ethyl and phenyl magnesium bromides, ethyl and phenyl-cyanoethyldichlorosilanes were prepared, the last not being previously described in literature. By a full or partial esterification of various cyanoethylchlorosilanes the authors obtained: B-cyanoethyltriethoxysilane, ethyl-S-cyanoethyldichlorosilane, S-cyanoethyltriacetoxysilane,

Synthesis of organosilicon ...

S/079/62/032/006/006/006 D202/D304

methyl-ß-cyanoethyldiethoxychlorosilane, and 6 new compounds: ß-cyanoethyldiethoxychlorosilane, ß-cyanoethyldibutoxychlorosilane, ß-cyanoethylbutoxydichlorosilane, methyl-ß-cyanoethyldibutoxysilane, methyl-ß-cyanoethyldi-iso-butoxysilane and ethyl-ß-cyanoethyldiacetoxysilane.

SUBMITTED: June 30, 1961

Card 2/2

S/080/62/035/007/006/013 D214/D307

AUTHORS:

Turetskaya, T.A., Golubtsov, S.A., Tromimova, I.V.

and Andrianov, K.A.

TITLE:

The influence of additions of some metals on the activity of silicon-copper alloy in its reaction

with ethyl chloride

PERIODICAL:

Zhurnal prikladnoy khimii, v. 35, no. 7, 1962,

1496-1502

TEXT: The general and selective activities of Si-Cu alloys in the reaction with EtCl to give a mixture of ethyl chlorosilanes are affected by the chemical nature of the alloy. The presence of 1-2% Fe, Al, Ca or Ti in the alloy increases its general activity, while Al, Ca and Ti also increase its selective activity by increasing the yield of EtSiHCl2. The increase in activity is more evident at low Cu concentrations. The added metals are localized at the interphase boundaries in the alloy, these being the active centers in the reaction. The influence Ca bears on the activity of the

Card 1/2

The influence of additions ...

S/080/62/035/007/006/013 D214/D307

of the alloy is affected by the presence of other metals. Fe in concentrations of up to 10%, does not influence the process. Concentrations of Bi and Sb of the order of 0.001% influence the selective activity and increase the yield of Et2SiCl2. Pb, in these concentrations, acts as a catalytic poison. At higher concentrations, both Bi and Sb also become poisons and at concentrations of 0.01% these metals render the alloy inactive. The mechanism of the action of the added metals cannot as yet be explained. There are 4 figures and 6 tables.

SUBMITTED:

December 9, 1960

Card 2/2

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actificate: Turetskaya, R. A., Golubtsov, S. A., Andrianov, K. A.,
Tsvanger, T. A., Prigozhin, B. Yu.

Direct synthesis of ethyl chlorosilanes

PLATORICAL: Khimicheskaya promyshlennost', no. 1, 1965, 18 - 20

TEXT: A method of directly synthetizing ethyl chlorosilanes in a functional dead at 360 - 380°C, wherein ethyl chlorosilanes in a series with a copper-silicon alloy was leser being these atters in a series with a copper-silicon alloy was leser being these atters in a series with a copper-silicon alloy was leser being these atters in a series with a copper-silicon was an action of the series of the series of the series of the prisent paper. The covering the series with a considered in the prisent paper. The covering the series of 250 kg alloy) and series to the ethyl chlorosil and The interior of and kg of contact this being 270 - 700 g in lab t sts and of the approximately that the prisent plant. The organization of the principle is due to the longer of that the approximately than the pilot plant. The organization is sequence: head fraction;
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\$/064/63/000/001/002/007 Direct synthesis of ethyl ...  $_{2}^{H_{5}}$  =1HCl2;  $_{2}^{H_{5}}$ SiCl3;  $_{2}^{H_{5}}$ )2SiHCl;  $_{2}^{H_{5}}$ )2SiCl3, and residue. The data of lab tests in method A are the following, contact mass of Cu-Si alloy containing 20 % Si: 0, 27, 20, 7, 37, 9; method B, addition of 27 - 28 % by volume of  $H_2$  during the experiment: 3, 41, 16, 11, 18, 10; method C, addition of 20 - 23.5 % by volume of HCl during the experiment: 11, 49, 16, 4, 16, 6; method D, addition of alloy Paring the experiment: 7. 51, 18, 5, 16, 8, and method E contact mass 1-dr willow containing 30, 0, 20, 11 for method D, and 4, 20, 28, 0, 38, 10 for method E. The and a promoted by Sb showed an increase in action with indicate lietayl notilizar great, whereas the Ath 1000 colors in 301 addition diving the experience induction addersoly the confidence and ethane by the process result in the ethyl chloride. on a standard of polyethyl siloxanes from ethyl chlorosilanes is compared That from ethyl ethoxysilanes. In the first case, 5.2 t and in the or case 10.0 t of raw material is required per non-fit of the The of the apparatus per unit voluce, ollowers. From House is

Direct synthesis of ethyl ...

\$/064/63/000/001/002/007 B101/B166

三十二次 為特別

Annil in the first case and 2.4 g/hr-l in the second case. Further improvements are possible by increasing the yield of dietnyl dichlorosilane and by complete inhibition of the formation of dehydrochlorination of dehydrochlorination.

Card 3/3

### S/062/63/000/001/012/025 B101/B186

AUTHORS: Golubtsov, S. A., Turetskaya, R. A., Andrianov, K. A., and Vabel', Ya. I. (Deceased)

TITLE: Formation of alkyl (aryl) chloro silanes by direct reaction of an alkyl (aryl) chloride with silicon. Communication 3. Direct synthesis of ethyl dichloro silane

PERIODICAL: Akademiya nauk SSSR. Izvestiya. Otdeleniye khimicheskikh nauk, no. 1, 1965, 87 - 90

Formation of alkyl ...

S/062/63/000/001/012/025 B101/B186

alloy containing 17% Cu at 370°C. Results: After 3 hrs reaction, the content of I in the reaction product was 12-19%; the other components of the reaction product were ethyl trichloro silane and diethyl dichloro silane. 20 min after adding 13% fresh Cu-Si alloy, the content of I rose to 51.5 - 59%, the rate of formation of ethyl chloro silanes had increased to the 2.5-fold. In a continuous experiment with supply of Cu-Si every 30 min, the process was stabilized after 8 hrs. The Cu content in the contact mass rose from 17 to about 35%, the content of I from 15-23 to 50-55%, and the formation of ethyl chloro silanes from 418 g/hr to 725 g/hr per kg of alloy. These values remained constant for 240 hrs. There are 3 figures and 2 tables

SUBMITTED: April 25, 1962

Card 2/2

L 10595-63 EWP(j)/EPF(c)/EWT(m)/BDS ASD Pc-L/Pr-L RM/WW ACCESSION NR: AP3000943 S/0064/63/000/003/0011/0018

65

AUTHOR: Turetskaya, R. A.; Golubtsov, S. A.; Trofimova, I. V.; Andrianov, K. A.

TITLE: The influence of some kinetic and hydrodynamic conditions on the direct synthesis of ethylchlorosilanes n

SOURCE: Khimicheskaya promyshlennost<sup>1</sup>, no. 3, 1963, 11-18

TOPIC TAGS: Cu-Si alloy, kinetic conditions, hydrodynamic conditions, ethyl-

ABSTRACT: The optimum particle size of Gu-Si alloy (75-250 microns) for the direct synthesis of ethylchlorosilanes, and the critical rate of fluidizing the alloy in the stream of ethyl chloride in reactors of 20-100 mm diameter, were determined. Investigation of reagent contact time, in intervals from 0.3-6.0 sec., on the parase of reaction showed composition of reaction products was practically independent of contact time. Optimum synthesis temperature was 360-3800 (300-390 degrees range investigated). Change in properties of catalyst and its effect on reaction with ethyl chloride was investigated. Originary, has a 16 figures.

ASSOCIATION: none

Card 1/2/

TURETSKAYA, R. A.; GOLUBTSOV, S. A.; TROFIMOVA, I. V.; ANDRIANOV, K. A.

Effect of some kinetic and hydrodynamic conditions on the direct synthesis of ethylchlorosilanes. Khim. prom. no.3: 171-178 Mr '63. (MIRA 16:4)

(Silane)

APPROVED FOR RELEASE: 06/13/2000 CIA-RDP86-00513R000515920010-8"

LOBUSEVICH, N.P.; LAYNER, D.I.; TROFIMOVA, I.V.; MALYSHEVA, L.A.; ANDRIANOV, K.A.; GOLUBISOV, S.A.

Reactions of alkyl (aryl) chlorosilane formation by the direct interaction between alkyl (aryl) chlorides and silicon. Report No.5: Phase composition of silicon-copper contact masses in reactions with methyl chloride. Izv. AN SSSR Ser.khim. no.10:1757-1766 0 163.

(MIRA 17:3)

1. Nauchno-issledovatel'skiy i proyektnyy institut splavov i obrabotki tsvetnykh metallov.

POPFLEVA, G.S.; ANDRIANOV, K.A.; COLUBTSOV, S.A.; PQPKOV, K.K.

Thermal addition of hydrochlorosilanes to alkenylchlorosilanes. Izv. AN SSSR. Ser. khim. no.11:2041-2042 N '63. (MIRA 17:1)

APPROVED FOR RELEASE: 06/13/2000 CIA-RDP86-00513R000515920010-8"

**计算机器 1997年** 

EMP(j)/EPF(c)/EMT(m)/EDS ं ५ सूच # P70025,27 Turetskaya, R. A.; Trofimova, I. V.; Andrianov, K. A.; Golubtsov, S. The question of the role of the phase structure of silicon-copper cont. t masses in the direct synthesis of ethylchorosilanes of SOURCE: Zhurnal obshchey khimii, v. 33, no. 6, 1963, 2015-2018 TOPIC TAGS: phase structure, silicon-copper, synthesis, ethylchorosilane, Cu sub 3 Si, silane, catalyst, ethyl chloride, dehydrochlorination, ethydichlorosilane, diethyldichlorosilane ABSTRACT: According to data obtained as well as literature, the role of the intermetallic Cu sub 3 Si compound, which disintegrates because of Si reacting with athylchloride and which is regenerated in the process, because in the formation (silanes) and partial renewal (of the catalyst. The observation and the selective antivity of stalyst entivity in at the reaction; product yields are essentially the same whether contact The season of the sub 3 St, or just a mixture of the suit of the set of with additives) and the set of the set 1/2 Card Para da de la compania de la compan La compania de la co

The Try lede (from ethyl chloride) on contact with Qu-catalyst is almost the case in ping notably with time. This is the activity recommendation is assumed to determine the selective from tion of

fightherosilane (in preference to disthyldical most are to the direct

s, Clauts process. Orig art. bas: 1 figure, a tables

ASSOCIATION: None

1 123/19-63

SUBMITTED: 26Apr62 DATE ACQ: 20Jul63 ENCL: 00

SUB CODE: 00 NO REF SOV: 010 OTHER: 001

Card 2/2

L 18899-63 EWP(j)/EPF(c)/EWI(m)/BDS ASD Pr-L/Pc-L RM/WW/MAY ACCESSION NR: AP3006593 S/0020/63/151/006/1329/1331

AUTHORS: Golubtsov, S. A.; Andrianov, K. A. (Corr. member AN SSSR); 69 Turetskaya, P. A.; Belikova, Z. V.; Trofimova, I. V.; Morozov, N. G.

TITLE: Reaction mechanism in the formation of dialkyldichlorosilanes

SOURCE: AN SSSR. Doklady\*, v. 151, no. 6, 1963, 1329-1331

TOPIC TAGS: dialkyldichlorosilane, dichlorosilane, silane, silicon chloride, copper chloride, hydration, methyl chloride, alkyl chloride

ABSTRACT: Authors showed that during the interaction of alkyl chloride with silica in the presence of copper, dialkyldichlorosilanes are formed. Copper monochloride, which is formed during the reaction of methyl chloride with copper, plays an important part in the synthesis of dialkyldichlorosilanes. The process consists of the adsorption of alkylchloride and its interaction with copper forming CuCl. Copper monochloride reacts with silica forming an intermediate product SiCl<sub>2</sub>. The removal of CuCl from the reaction zone by means of hydration with hydrogen, results in the discontinuation of

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ACCESSION NR: AP4018162

S/0191/64/000/003/0022/0024

AUTHORS: Lobusevich, N.P.; Trofimova, I.V.; Andrianov, K.A.;

Golubtsov, S.A.

TITLE: Effect of metal halides on the activity of silicon-copper

alloys in the synthesis of methylchlorosilanes.

SOURCE: Plasticheskiye massy\*, no.3, 1964, 22-24

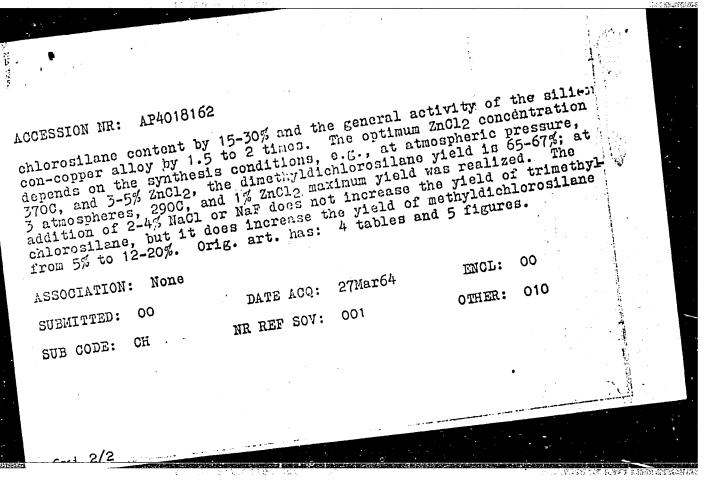
TOPIC TAGS: silicon copper catalyst, catalyst activity, methylchlorosilane synthesis, dimethyldichlorosilane synthesis, cuprous chloride, zinc chloride, silicon copper alloys, sodium halide, catalyst activator, metal halides

ABSTRACT: Activation of silicon-copper alloys containing 20% silicon with 3-7% CuCl increases the dimethyldichlorosilane content in the mixture of methylchlorosilanes by 10-20% in reactions at 4.5-5 atmospheres pressure. (no favorable results at atmospheric pressure); the optimum temperature is 3600. ZnCl<sub>2</sub> appears to be a more effective activator than CuCl since its introduction increases the dimethyldi-

Gard 1/2

# "APPROVED FOR RELEASE: 06/13/2000

# CIA-RDP86-00513R000515920010-8



ACCESSION NR: AP4034567

8/0079/64/034/004/1111/1113

AUTHOR: Popeleva, G. S.; Andrianov, K. A.; Larionova, A. A.; Golubtsov, S. A.

TITIE: Thermal condensation of dimethylchlorosilane with certain organic chloro-derivatives.

SOURCE: Zhurnal obshchey khimii, v. 34, no. 4, 1964, 1111-1113

TOPIC TAGS: dimethylchlorosilane, thermal condensation, dimethylvinylchlorosilane, dimethylallylchlorosilane, a chlorovinyldimethylchlorosilane, bis dimethylchlorosilyl ethylene, p chlorophenyldimethylchlorosilane, disproportionation, monofunctional derivative, polyfunctional derivative, distillation, purification, etherification

ABSTRACT: This is a continuation of earlier investigations of the thermal condensation of chlorosilanes with different chloro-organic compounds. In this investigation the thermal condensation (at 500-550 C) of chloroorganics with dimethylchlorosilane were studied:

(CH<sub>3</sub>)<sub>2</sub>SiHCl + RCl -> (CH<sub>3</sub>)<sub>2</sub>RSiCl + HCl. R = CH<sub>4</sub>=CH, CH<sub>4</sub>=CHCH<sub>4</sub>, CHCH=CM, CHC<sub>4</sub>=-

Card 1/2

ACCESSION NR: AP4034567

Dimethylvinylchlorosilane, dimethylallylchlorosilane, and compounds not described in the literature, beta-chlorovinyldimethylchlorosilane, bis(dimethylchlorosilyl)ethylene, and p-chlorophenyldimethylchlorosilane were prepared by this method. In the high temperature condensation process disproportionation of the dimethylchlorosilane takes place with the formation of dimethyldichloro-, methyl-dichloro- and trichlorosilanes, which in turn condense with the chloroorganics to form di- and tri-functional compounds whose boiling points are near those of the desired monofunctional compounds. These cannot be separated even by repeated distillation. It was found the monofunctional compounds may be purified by partial etherification of the polyfunctional impurities with isobutyl alcohol.

ASSOCIATION: None

SURVITTED: 19Jan63

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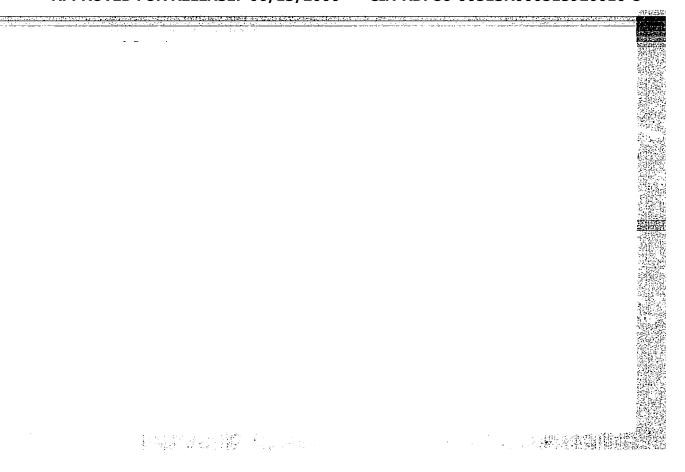
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OTHER: 005

Card 2/2

Reaction mechanism of addition of hydrides of chlorosilanes to acrylonitrile, Zhur. ob. khim. 34 no. 5:1480-1484 My '64.

APPROVED FOR RELEASE: 06/13/2000 CIA-RDP86-00513R000515920010-8"





LOBUSEVICH, N.P.; TROFIMOVA, I.V.; ANDRIANOV, K.A.; GOLUETSOV, S.A.

Effect of mositure, methanol, and oxygen in methyl chloride on the synthesis of methylchlorosilanes. Zhur.prikl.khim. 37 no.5:1148-1152 My '64. (MIRA 17:7)

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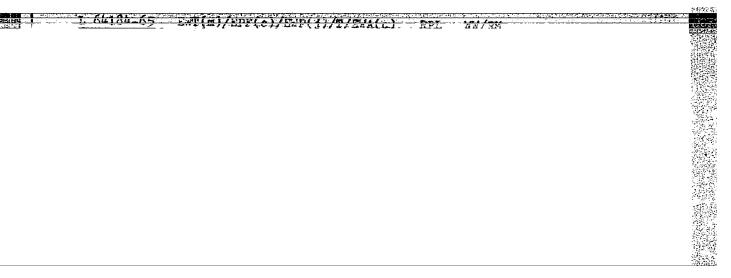


Cu01 = 81 showed that even at low temperatures (1800), the ratios of peak

allano gave 32% y strilluoropropylidavidiokiorostiana and the life i y lain......

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COLUBTSOV, S.A., BELYAKOVA, Z.V., POMERANTSEVA, M.C.

acting the chlorosilanes with perfluoro-lil-dihvarabuty; assetties in

Cleavage of siloxanes by silicon tetrachloride. Zhur. ob. khim. 35 no.631044-1048 Je '65.

Reaction of silane hydrides with allyl chloride. Ibid.:1048-1052 (MIRA 18:6)

APPROVED FOR RELEASE: 06/13/2000 CIA-RDP86-00513R000515920010-8"

BELYAKOVA, Z.V.; COLUBTSOV, S.A.; YAKUSHEVA, T.M.

Addition of trichlorosilane to acrylonitrile and allyl cyanide.
Zhur. ob. khim. 35 no.7:1183-1186 Jl \*65. (MIRA 18:8)

L 1255-66 EPF(c)/EWP(j)/EWT(m)/T ACCESSION NR: AP5021674 UR/0080/65/038/008/1887/1889 AUTHOR: Lobusevich, 44,55 547. 211'222'245 Trofimova, S. A. 44.55 V.; Andrianov, K. U.56 TITLE: Effect of methyl chloride and vinyl chloride on the synthesis of methylchlorosilanes 1 4455 SOURCE: Zhurdal prikladnoy khimii, v. 38, no. 8, 1965, 1887-1889 TOPIC TAGS: chloride, silane, methylene chloride, vinyl chloride, catalysis, ABSTRACT: Methyl chloride obtained by chlorination of natural gas contains up to 1.7 vol. % methylene chloride and 0.2-3.0% vinyl chloride. It is known that at temperatures of 300-350C methylene chloride reacts with silicon copper catalysts with formation of hexachlorodisilane methane and also of hydrogen containing chlorosilanes. Under the conditions of the reaction of methyl chloride with silicon-copper catalysts, the methylene chloride can react with the silicon with information of analogous compounds, and can undergo decomposition with the formation of carbon, which deactivates the catalyst. Carbonization of the catalyst was observed even after short term synthesis, with the introduction of

L 1255-66

ACCESSION NR: AP5021674

6-7% of methylene chloride into the methyl chloride. In experiments in a pressurized fluidized bed on an alloy promoted with antimony, an investigation was made of the effect of vinyl chloride, whose concentration in the mixture with methyl chloride was varied from 0.16 to 4.0 vol. %. No adverse effect on the process was observed at concentrations up to 0.2%. In the reaction of methyl chloride with an alloy of the composition Cu<sub>3</sub>Si, vinyl chloride in concentrations higher than 0.16% sharply lowers overall activity and slightly lowers selective activity. For Cu<sub>3</sub>Si alloys and mixtures of copper and silicon powders with addition of 0.5% aluminum, the introduction of more than 0.16% vinyl chloride causes a greater decrease in overall activity than for catalysts with an antimony additive. In this case, large amounts of still residues are formed (15-40%). In general, it is concluded that under the conditions of the synthesis, vinyl chloride reacts with silicon with the formation of vinyl trichlorosilane, ethyl dichlorosilane, and dimethyl vinyl chlorosilane, and that this inhibits the separation of dimethylchlorosilane from the mixture of methylchlorosilanes. Orig. art. has: 3 figures and 1 table

SUBMITTED: 17Jun63

ENCL: 00 NR REF SOV: 003

OTHER: 002 Card 2/2 K

APPROVED FOR RELEASE: 06/13/2000 CIA-RDP86-00513R000515920010-8"

SUB CODE: MM, GC

BYKOVCHENKO, V.G.; ERMANSON, L.V.; GOLUBTSOV, S.A.

Effect of inhibitors on the reaction of trichlorosilane with chlorobenzene. Zhur. fiz. khim. 39 no.2:450-451 F 165. (MIRA 18:4)

SHAPATIN, A.S.; GOLDETSOV, S. 1.; SOLOVIYEV, A.A.; ZHIGACH, A.F.;
SIRYATSKAIA, V.N.

Addition of silicon chloride hydrides to alkenyl carboranes.
Plast. massy no. 12:19-21 165

(MIRA 19:1)

APPROVED FOR RELEASE: 06/13/2000 CIA-RDP86-00513R000515920010-8"

L 15790-66 EWT(m)/EWP(j) RM ACC NR: AP6002225

SOURCE CODE: UR/0080/65/038/012/2882/2885

AUTHOR: Lobusevich, N. P.; Trofimova, I. V.; Andrianov, K. A.; Golubtsov, S. A.

ORG: none

TITLE: Effect of dimethyl ether, carbon dioxide, and carbon monoxide on the synthesis of methylchlorosilanes

SOURCE: Zhurnal prikladnoy khimii, v. 38, no. 12, 1965, 2882-2885

TOPIC TAGS: carbon monoxide, copper containing alloy, carbon dioxide

ABSTRACT: The effect of dimethyl ether in the reaction between methyl chloride with silicon alloys containing 20% Cu and 10% Cu, respectively, activated by 0.002--0.004% Sb in the boiling layer at atmospheric and higher pressures was studied. Carbon dioxide and carbon monoxide (0.5-14.5%) were studied in the same reaction at atmospheric pressure using various contact masses. It was found that dimethyl ether, carbon monoxide and, under certain conditions, carbon dioxide are contact inhibitors of the reaction which produces methylchlorosilanes. The inhibiting effect of carbon dioxide and dimethyl ether is attributed to carbon monoxide which causes ir-

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16200-66 ENT(m)/EWP(j)/T

AP6002226

SOURCE CODE: UR/0080/65/038/012/2886/2887

AUTHOR: Lobusevich, N. P.; Trofimova, I. V.; Andrianov, K. A.; Golubtsov, S.

ORG: none

8 TITLE: Chemisorptive action of impurities and the effect of chlorosilanes and methylchlorosilanes

SOURCE: Zhurnal prikladnoy khimii, v. 38, no. 12, 1965, 2886-2887

TOPIC TAGS: chemisorption, chlorosilane, copper containing alloy, milicon containing alloy

ABSTRACT: The chemisorptive mechanism of action of the impurities is experimentally confirmed by introducing reaction products, chlorosilanes and methylchlorosilanes, into methyl chloride. It has previously been noted that the mechanism of action of the impurities is associated with their adsorption on the active centers and with the pitting of the copper catalyst. The introduction of from 0.5 to 2.0% of chlorosilanes or methylchlorosilanes into methyl chloride results in a two to threefold increase in productivity and an increase of dimethyldichlorosilane in the mix-

UDC: 661.723-13

Card 1/2

L 16200-66

ACC NR: AP6002226

ture. The different effects of reaction products on the interaction of the alloys with pure and technical methyl chloride is apparently associated with the selective adsorption of impurities. The introduction of insignificant amounts of reaction products into methyl chloride and the preliminary treatment of the alloys with chlorosilanes or methyl chlorosilanes result in their selective adsorption on the catalyst which prevents pitting of the catalyst by harmful impurities and improves the indicators of the process. It is shown that the activity of the reaction products from methyl chloride and silicon in preventing the harmful effect of impurities increases in the series: HSiCl<sub>3</sub> > SiCl<sub>4</sub> > CH<sub>3</sub>SiC<sub>3</sub> > (CH<sub>3</sub>)<sub>3</sub>SiCl > (CH<sub>3</sub>)<sub>2</sub>SiCl<sub>2</sub> > > CH3HSiCl2. Orig. art. has: 2 tables.

ORIG REF: 001/ OTH REF: 000 SUBM DATE: 09Jul63/ SUB CODE: 07/

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### CIA-RDP86-00513R000515920010-8

I. 1/1612-66 EWT(m)/T/EWP(1) WW/JW/RM ACC NRI AP6001497 SOURCE CODE: UR/0191/65/000/012/0019/0021 AUTHORS: Shapatin, A. S.; Golubtsov, S. A.; Solov'yev, A. A.; Zhigach, A. Siryatskaya, V. N. ORG: none TITLE: Addition of hydrides of silicon chlorides to alkenyl carboranes SOURCE: Plasticheskiye massy, no. 12, 1965, 19-21 TOPIC TAGS: silane, organic synthetic process, catalysis, silicon compound, catalyst, ferric chloride ABSTRACT: A simplified method for synthesizing carborane siliconorganic monomers is offered. It consists of adding chlorosilicon hydrides to alkenyl carboranes, according to the equation: The following reactions were studied: methyldichlorosilane with carborane derivatives containing vinyl, isopropenyl, propenyl, or butenyl groups; trichlorosilane and dimethyl chlorosilane with vinyl and isopropenyl carborane; ethyl dichlorosilane and phenyldichlorosilane with isopropenylcarborane. Elementary analysis and UDC: 678.84

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physical p	properties o	f the resulti	ng 10 com	oounds s	re remorte	d To	the abo	orac (	ノ
or rue car	alyst the r	eaction occur	s only abo	ve 2000	and resul	ta in v	arry low	retald	is.
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L 13901-66 EWT(m)/EWP(1) RM ACC NR: AP6002863 SOURCE CODE: UR/0286/65/000/024/0020/0020 INVENTOR: Popov, A. F.; Korneyev, H. H.; Golubtsov, S. A.; Popeleva, P. S. ORG: none TITLE: Preparative method for bis (dimethylchlorosilyl) benzene Class 12, No. 1768926 SOURCE: Byulleten' izobreteniy i tovarnykh znakov, no. 24, 1965, 20 TOPIC TAGS: silene ABSTRACT: An Author Certificate has been issued for a preparative method for bis (dimethylchlorosilyl) benzene, involving the reaction of metallic magnesium with p-dibromobenzene and dimethyldichlorosilane. To simplify the process, it is carried out in the presence of 0.001-0.01 g-mol titanium tetrachloride catalyst/mol metallic magnesium. [SK] SUBM DATE: 22Ju164/ ATD PRESS: 4/9/ SUB CODE: 07/ UDC 547.419.5.07

L 20977-66 EWT(m)/EWP(j) RM

ACCESSION NR: AP5021673

UR/0080/65/038/008/1884/1886

547, 222

AUTHOR: Lobusevich, N. P.; Trofimova, I. V.; Andrianov, K. A.; Golubtsov,

TITLE: Effect of sulfur dioxide on the synthesis of methylchlorosilanes

42

SOURCE: Zhurnal prikladnoy khimii, v. 38, no. 8, 1965, 1884-1886

B

TOPIC TAGS: silane, catalysis, sulfur compound, silicate, copper, silicon, aluminum, antimony, chloride

ABSTRACT: The effect of sulfur dioxide was evaluated with respect to the yield and the content of dimethylchlorosilane in the mixture. With a content of sulfur dioxide greater than 0.002% in methyl chloride, there is a decrease in the overall activity of copper silicate promoted with antimony. A decrease in selective activity in the synthesis of dimethylchlorosilane is observed with an increase in concentration of sulfur dioxide from 0.002 to 0.01% and at concentrations from 0.01 to 1.0% the content of dimethylchlorosilane is practically unchanged. Selective activity of alloys with the composition Cu<sub>3</sub>Si(eta phase) in the absence of a promoter, as well as of mixtures of copper and silicon powders, decreases more rapidly than the activity of analogous alloys containing 0.005% antimony.

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ACCESSION NR: AP5021673

With an increase in concentration of sulfur dioxide up to 2%, the synthesis of methylchlorosilanes over all the above catalysts stops. A particularly strong effect of sulfur dioxide is observed on the activity of alloys with increased content of aluminum (1% in an alloy with silicon and 87% copper). At sulfur dioxide concentrations of 0.002% the synthesis ceases. Mixtures of copper, silicon, and aluminum powders have a satisfactory and stable overall activity, but the selective activity decreases. With an increase in titanium content (0.5%) in alloys or in mixtures of copper and silicon powders, the introduction of sulfur dioxide into the methyl chloride leads to a decrease in activity and to a sharp increase in content of high melting products (up to 40% of the weight of the methyl-chlorosilane mixture). It was found that with an increase in reaction time of methyl chloride with a mixture of copper and silicon powders in the presence of 0.8% sulfur dioxide, the poisoning effect of the latter becomes stronger. Orig. art has: 5 figures and 1 table

ASSOCIATION: None SUBMITTED: 17Jun63

NR REF SOV: 001

ENCL: 00 OTHER: 000 SUB CODE:

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Card 2/2 MQ.S

L 23717-66 ENT(m)/EWP(1)/T ACC NR: AP6007118 SOURCE CODE: UR/0079/66/036/002/0345/0347 AUTHOR: Lobusevich, N. P.; Golubtsov, S. A.; Layner, D. I.; Halysheva, L. A.; Trofimova, I. V. ORG: none TITLE: On the problem of promotors and poisons in the direct synthesis of methylchlorosilanes SOURCE: Zhurnal obshchey khimii, v. 36, no. 2, 1966, 345-347 TOPIC TAGS: silane, bismuth, phosphorus, antimony, copper alloy, silicon alloy, zinc chemical dacomposition ABSTRACT: The kinetics of the decomposition of Cu<sub>3</sub>Si were studied during its reaction with methyl chloride in the presence of promotors (arsenic, phosphorus mixed with antimony and zinc) and contact poisons (bismuth and phosphorus). Addition of the most active promotors lowers the temperature at which the Cu<sub>3</sub>Si alloy begins to react with methyl chloride from 330° to 270°C in the case of arsenic and from 330° to 290°C in the case of the phosphorus-antimony mixture. The activation energy of the reaction between Cu<sub>3</sub>Si and methyl chloride decreases by one-half when these promotors are introduced. The action of the zinc promotor increases the reaction rate, but the activation energy remains practically unchanged. Apparently, elemental zinc converts into zinc chloride which accelerates the reaction of dimethyldichlorosilane formation. Ad-Card 1/2

dition chlori	of bismu de even a	th or pho t high te	sphorus shar mperatures (	ply inhi 390°C).	bit the r Orig. ar	eaction o t. has:	f Cu <sub>3</sub> Si w 1 figure.	ith me	thy1	
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ACC NR: AP6007125	SOURCE CODE: UI	R/0079/66/036/002/0364/0364	
AUTHOR: Ponomarev, V.	V.; Shapatin, A. S.; Golubtsov, S. A	1. 29 23	1
ORG: none		, ŽŠ	
TITLE: Reaction of pho	osphorus pentachloride with trimethyl	lallylsilane	
SCURCE: Zhurnal obshch	ney khimii, v. 36, no. 2, 1966, 364	:	
TOPIC TAGS: organophos chloride, chemical mach	sphorus compound, organosilicon compo	ound, silane, phosphorus	
ABSTRACT: The reaction silicon compound, trime	of phosphorus pentachloride (I) with the other of the following the foll	th an unsaturated organo; owing reaction:	
(CH <sub>3</sub> ) <sub>3</sub> Si-CH <sub>2</sub> -C	$CH = CH_3 + \frac{1}{2} CI_1 + \frac{1}{2} CI_0 \longrightarrow (CH_3)_3 SI - CH_2 - CHCI - CH_3$	PCI;PCI <sub>6</sub> so,	
	$\longrightarrow (CH_3)_3SI-CH_2-CHCI-CH_2-P(0)Ci_3$ (H1)	(1)	-
On heating, product (II	I) decomposes to form trimethylchlor	osilane (IV) and allylphos	- -
phonyl dichloride (V):	(III) $\longrightarrow$ (CII <sub>3</sub> ) <sub>3</sub> SiCl $+$ CH <sub>2</sub> =CH-CH <sub>2</sub> -P(0)Cl <sub>2</sub> <sup>2</sup> (IV) (V)	(2)	-
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SUB CODE: 07/ SUBM DATE: 04Mar65/ ORIG REF: 001/ OTH REF: 002		sence of chl that the add rule. The a	of reaction ( lative to sil lorine in (II lition of the	icon, demonstrates $\mathfrak{t}$ : I) in the $\mathfrak{g}$ position $\mathfrak{t}$ chloride (I) to the $\mathfrak{t}$ $\mathfrak{g}$ . Ionin for his	he structure relative to alkenvlsila	of comp phosphone (II)	ing chlorine in the β cound (III). The pre- orus indicates in turn follows Markovnikov's discussion of the	_
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CIA-RDP86-00513R000515920010-8

L 39718-66 EVT(m)/EWP(j)/T RM/GD-2

ACC NR. AP6007969 (A) SOUCE CODE: UR/0191/66/000/003/D036/0037

AUTHOR: Turetskaya, R. A.; Golubtsov, S. A.; Davonar', V. G.

ORG: none

TITLE: Synthesis of triphenylchlorosiland from silicon tetrachloride and phenyl-sodium

SOURCE: Plasticheskiye massy, no. 3, 1966, 36-37

TOPIC TAGS: organic synthetic process, silicon compound, organosilicon compound

ABSTRACT: Tetraphenylsilane was prepared from silicon tetrachloride and phenylsodium by the known reaction (Polis, Ber. 18, 1514, 1885). The authors studied the possibility of preparing triphenylchlorosilane from these reagents. By a thorough purification of benzene chloride and the solvent (by a treatment with calcium hydride, phosphorus pentoxide, and subsequently with  $H_2SO_4$ ) a 82-91% yield of phenylsodium was obtained from benzene chloride and sodium in toluene solution. Phenyl sodium was transferred to a mixing flask containing 33 wt.% SiGl<sub>4</sub> in toluene. After 1 hr of mixing, the reaction mixture was filtered in a  $N_2$  atmosphere and fractionally distilled at  $\leq$ 90, 90-170, 170-180, 180-220, 220-237, and 237-250C. A 70-74% yield of triphenylchlorosilane was obtained in fractions at 220-250C. Tetraphenylsilane (9-14%) and diphenyldichlorosilane (6-8%) were among the reaction products. The residue still contained 3.2% chlorine. A change of temperature from -30 to +20C did not affect the yield.

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UDC: 546.281

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L 31889-66 EWT(m)/EWP(j)/T RM

ACC NR: AP6012529 (A) SOURCE CODE: UR/0062/66/000/003/0475/0478

AUTHOR: Morozova, L. P.; Andrianov, K. A.; Morozov, N. G.; Golubtsov, S. A.

TITLE: Formation of alkyl(aryl)chlorosilanes during direct reaction of alkyl(aryl)chlorides with silicon. Communication 5. Effect of secondary decomposition process of methyldichlorosilane on the synthesis of methylchlorosilanes

SOURCE: AN SSSR. Izvestiya. Seriya khimicheskaya, no. 3, 1966, 475-478

TOPIC TAGS: catalyst, methyldichlorosilane, silane, organic synthesis

ABSTRACT: It was found that in decomposition reactions of methyldichlorosilane the most active catalysts are those which possess high selectivity in the synthesis of methyldichlorosilane. When the activity of catalysts in the synthesis is increased so that the yield increases from 2.2 to 25.5 g of methyldichlorosilane per kg of mass per hour, the degree of decomposition of methyldichlorosilane under identical conditions also increases from 4.0 to 67.2% respectively. This is explained by the fact that both synthesis and decomposition of methyldichlorosilane occur on the same active centers. It was shown experimentally that the degree of decomposition of methyldichlorosilane in a stream of methyl chloride decreases by about 1 order of magnitude as compared with

UDC: 542.91+546.287+542.97

Card 1/2

ORG: none

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Card 2/2

L 31888-66 EWT(m)/EWP(j)/T

AP6012530 ACC NR:

(A)

UR/0062/66/000/003/0478/0482 SOURCE CODE:

Popeleva, G. S.; Andrianov, K. A.; Golubtsov, S. A. AUTHOR:

ORG: none

TITLE: Study of the reaction of methyl(chlorophenyl)chlorosilanes with hydrochlorosilanes

SOURCE: AN SSSR. Izvestiya. Seriya khimicheskaya, no. 3, 1966, 478-482

TOPIC TAGS: silane, organic synthesis, condensation reaction, substitution reaction

ABSTRACT: Using the previously described thermal condensation method [Authors Certificate No. 134699; Zh. obshch. khimii, 32, 557 (1962)] alkylchlorosilane hydrides were condensed with alkyl(chloroaryl)chlorosilanes by the following scheme:

 $Cl_{3-n}(CH_3)_nSiC_6H_4Cl + HSiR_mCl_{3-m} \rightarrow Cl_{3-n}R_nSiC_6H_4SiR_mCl_{3-m} + HCl$ 

where n=0, 1, 2, 3; m=0, 1, 2. The condensation reaction is accompanied by a side reaction involving the reduction of chlorine in the aryl radical by the hydrogen of chlorosilane hydride. The products of substitution of hydrogen at the silicon by chlorine can be formed also by the decomposition reaction in hydrogen chloride medium as follows:

 $HSiR_nCl_{3-n} + HCl \rightarrow SiR_nCl_{4-n} + H_2$  $Cl_{3-n}R_nSiC_6H_4SiR_mCl_{3-m} + HCl \rightarrow Cl_{3-n}R_nSiC_6H_5 + ClSiR_mCl_{3-m}$ 

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542.91+546,287 UDC:

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ACC NR: AP6012530

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Here in APPROVED FOR RETEASE: 06/13/2000. ICIA-RDB86-00513R600513920010-8 reduction reactions are approximately equivalent. ICIA-RDB86-00513R600513920010-8 can be substituted by chlorine, but also the organic radical connected to the silicon atom both in the starting materials as well as in the reaction products. The synthesized produces are: bis(trichlorosilyl)benzene, bis(dimethylchlorosilyl)benzene, 1--methyldichlorosilyl-4-trichlorosilylbenzene, 1-dimethylchlorosilyl-4-trichlorosilyl--benzene, 1-methyldichlorosilyl-4-dimethylchlorosilylbenzene, 1-trimethylsilyl-4-trichlorosilylbenzene and 1-trimethylsilyl-4-methyldichlorosilylbenzene. The best yield of silphenylene compounds was produced by chlorophenyltrichlorosilane (n=0), but as nincreases the yield of the principal product decreases. The investigated alkyl(chloroaryl)chlorosilanes are arranged in the following series in terms of their reactivity in the reaction of the formation of silphenyl derivatives:

 $\text{ClC}_0\text{H}_4\text{SiCl}_3 > \text{ClC}_0\text{H}_4\tilde{\text{Si}}(\text{CH}_3)\text{Cl}_2 > \text{ClC}_0\text{H}_4\text{Si}(\text{CH}_3)_2\text{Cl} > \text{ClC}_0\text{H}_4\tilde{\text{Si}}(\text{CH}_3)_3.$ 

1 figure. Orig. art. has:

SUBM DATE: 12Nov63/

ORIG REF: 006/

OTH REF:

SUB CODE: 07/

1_41315-66 EWT(m)/EWP(j) RM	•	
ACC NR: AF6024019	SCURCE CODE: UR/CO62/66/000/006/1009/1016	The same of the sa
Turetskaya, R. A.; Andrianov, K. A.	V. V. (Deceased); Popkov, K. K.; Trofimova, I. V.; Belikova, Z. V.; Golosova, R. M.; Oygonblik, A. A.	
Aristova, V. G.	59	
ORG: none		
TITIE: Reactions of formation of a tween alkyl (aryl) chlorides and si the formation of dialkyldichlorosil	Ikyl(aryl)chlorosilanes in a direct interaction be- licon. Report No. 6. Role of cuprous chloride in anes 1	7
SOURCE: AN SSSR. Izv. Ser khim,	no. 6, 1966, 1009-1016	
TOPIC TAGS: silane, chloride, sili	con compound, copper compound, CHEMICAL REACTION	ر ر
ane and methyl(ethyl)trichlorosilar	for the formation of dimethyl(diethyl)dichlorosil- ne during the reaction of methyl (ethyl) chloride The proposed mechanism for the formation of dialkyl	
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#### CIA-RDP86-00513R000515920010-8

L 41315-65 O ACC NR: AP6024019  $RCI + Cu \rightarrow RCI \cdot Cu$  $2RCl \cdot Cu \rightarrow 2CuCl + 2R$  $Si + 2CuCl \rightarrow SiCl_2 + 2Cu$  $SiCl_2 + RCl \cdot Cu \rightarrow RSiCl_2 + CuCl$  $RSiCl_2 + RCl \cdot Cu \rightarrow R_2SiCl_2 + CuCl$  $Si + 2RCl \xrightarrow{\square} R_2SiCl_2$ The formation of alkyltrichlorosilane is represented as follows:  $Si + 2CuCl \rightarrow SiCl_2 + 2Cu$  $SiCl_2 + RCl \cdot Cu \rightarrow RSiCl_3 + Cu$ Experimental data obtained confirmed these mechanisms. Thermodynamic calculations of the initial stages of the reactions of methyl and ethyl chloride with silicon were performed. The formation of dichlorosilene is thermodynamically quite probable under the conditions of synthesis of alkylchlorosilanes. UV spectra of the products formed by the reaction of cuprous chloride with silicon showed a group of bands characteristic of the spectrum of SiCl2. Orig. art. has: 2 figures and 5 tables. SUB CODE: 07/ SUBM DATE: 12Feb64/ ORIG REF: 008/ OTH REF: 012

#### "APPROVED FOR RELEASE: 06/13/2000

### CIA-RDP86-00513R000515920010-8

L 43896-66 EWT(m)/EWP(j) SOURCE CODE: UR/0413/66/000/009/0024/0024 ACC NR. AP6015624 INVENTOR: Morozov, N. G.; Selik, G. I.; Andrianov, K. A.; Golubtsov ORG: none TITLE: Method of obtaining methychlorosilanes. Class 12, No. 181105 SOURCE: Izobreteniya, promyshlennyye obraztsy, tovarnyye znaki, no. 9, 1966, 24 TOPIC TAGS: methylchlorosilane, methyl chloride, silane ABSTRACT: An Author Certificate has been issued for a method of obtaining methylchlorosilanes by the interaction of methyl chloride with a silicon copper contact mass in the presence of an activator. To increase the content of trimethylchlorosilane in the mixture of terminal methylchlorosilanes, sodium aluminate chloride is [NT] used as the activator. [Translation] SUB CODE: 11/, SUBM DATE: 24Feb65/ UDC: 547.419.5.07

ACC NR: AP6030559 (A, N) SOURCE CODE: UR/0413/66/000/016/0033/0033

INVENTOR: Ponomarev, V. V.; Shapatin, A. S.; Golubtsov, S. A.

ORG: none

TITLE: Preparative method for silicon-containing organophosphorus compounds. Class 12, No. 184856

SOURCE: Izobreteniya, promyshlennyye obraztsy, tovarnyye znaki, no. 16, 1966, 33

TOPIC TAGS: ORGANIC phosphorus compound, silicon, alkylaryl silicon derivative, phosphorus trichloride, CHEMICAL REACTION

ABSTRACT: An Author Certificate has been issued for a method for preparing silicon-containing organophosphorus compounds of the general formula  $\text{Cl}_n \text{R}_n \text{Si}(\text{R'PCl}_2)_{4n-m}$ , where n=0-3, m=0-3, Ris a monovalent alkyl as arylalkyl group, and R' is a bivalent alkylaryl group. The method involves the reaction of alkylaryl silicon derivatives of the  $\text{R}_n \text{Cl}_{3-n} \text{Si}(\text{CH}_2)_n \text{C}_6 \text{H}_5$  type with PCl $_3$  in the presence of Friedel-Crafts reaction catalysts, e.g. AlCl $_3$ .

SUB CODE: 07/ SUBM DATE: 18May65/

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ORG: none

TITLE: Method of obtaining phenylchlorosilane. Class 12, No. 184855. [announced by State Scientific Research Institute of State Design and Planning Scientific Research for the Processing of Nonferrous Metals (Gosudarstvennyy nauchno-issledovatel'skiy institut "Giprotsvetmetobrabotka")]

SOURCE: Izobreteniya, promyshlennyye obraztsy, tovarnyye znaki, no. 16, 1966, 33

TOPIC TAGS: phenylchlorosilene, chlorobenzene

ABSTRACT: An Author Certificate has been issued for obtaining phenylchlorosilanes by the reaction of chlorobenzene with the silicon-copper contact mass in the presence of an activator. To raise the yield of diphenyldichlorosilane and to

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